

# Doping

► A manufacturing process that adds free charge carriers (free **electron** or **hole**) into a pure semiconductor material to increase its conductivity .

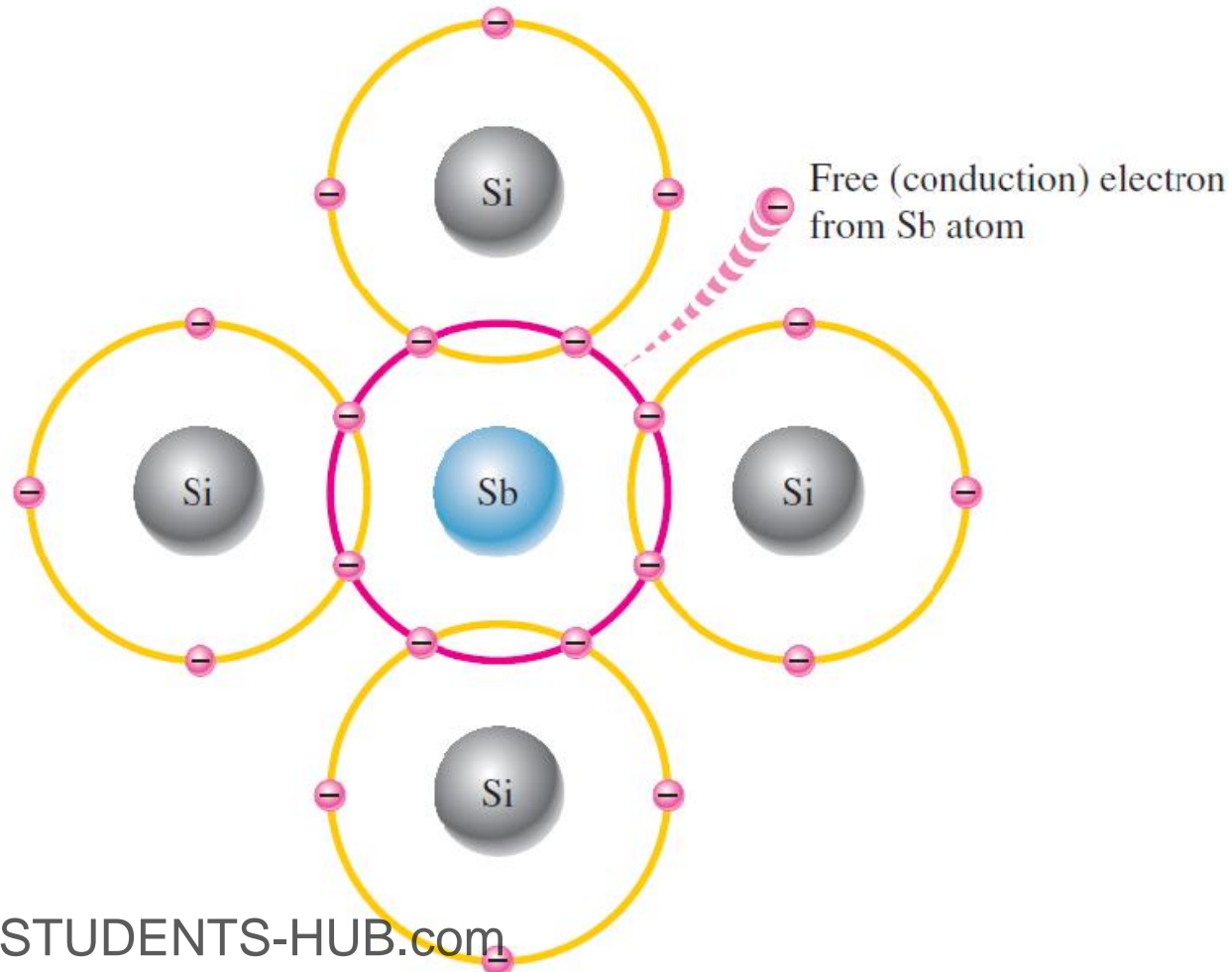
► Doping  **n**-type or **p**-type material

## N - type semiconductor

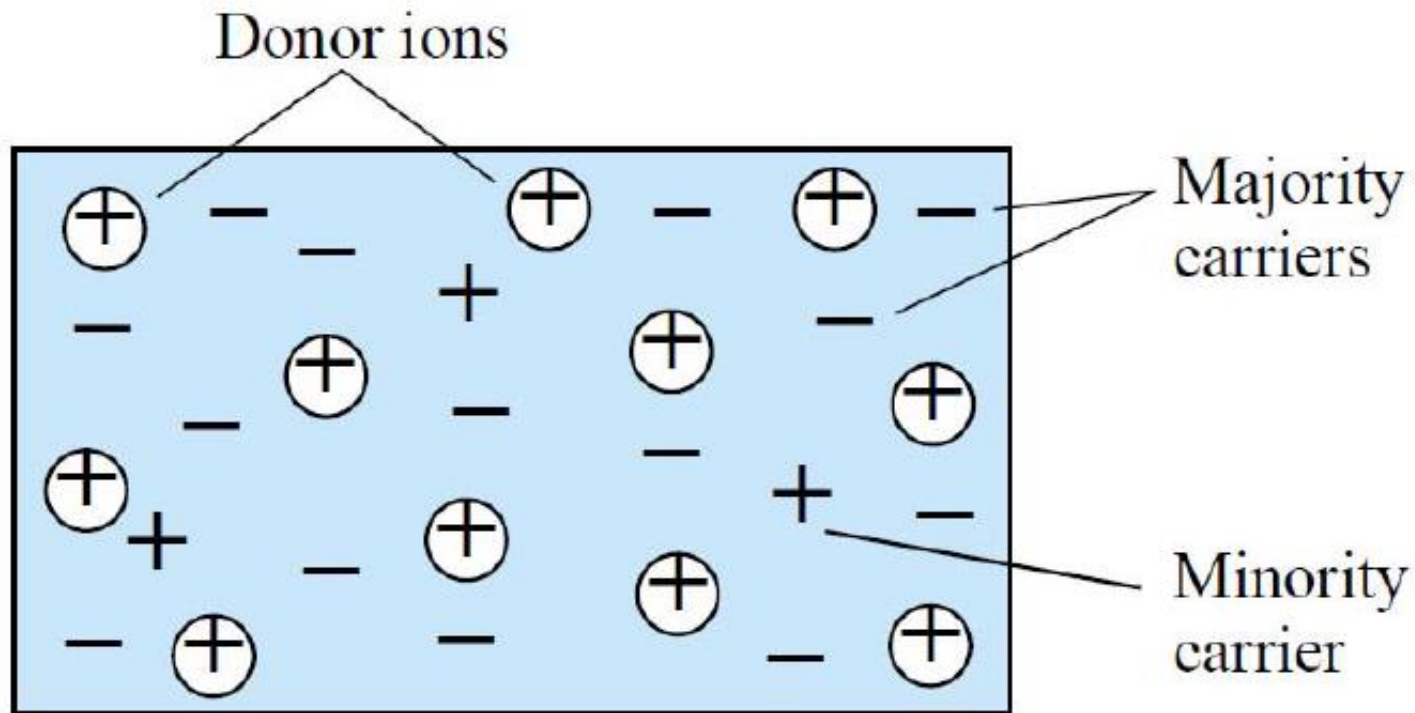
Sb (**antimony**) has five valence electrons and it is called **a donor atom**.

We add (  $10^{15} - 10^{17}$  ) Sb atoms/cm<sup>3</sup>

At room temperature there is  $5 \times 10^{22}$  atoms/cm<sup>3</sup> in pure Si .

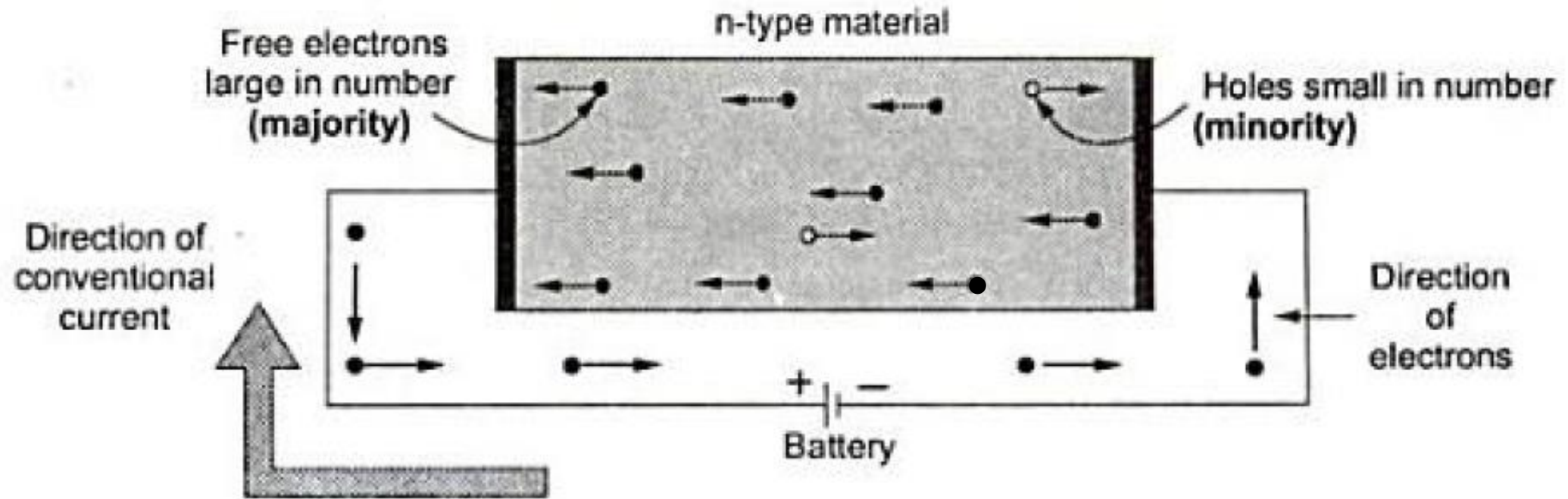


In the **n**-type material the free **electrons** are the **majority** and the **holes** are the **minority**.



*n*-type

# Conduction in n-type material



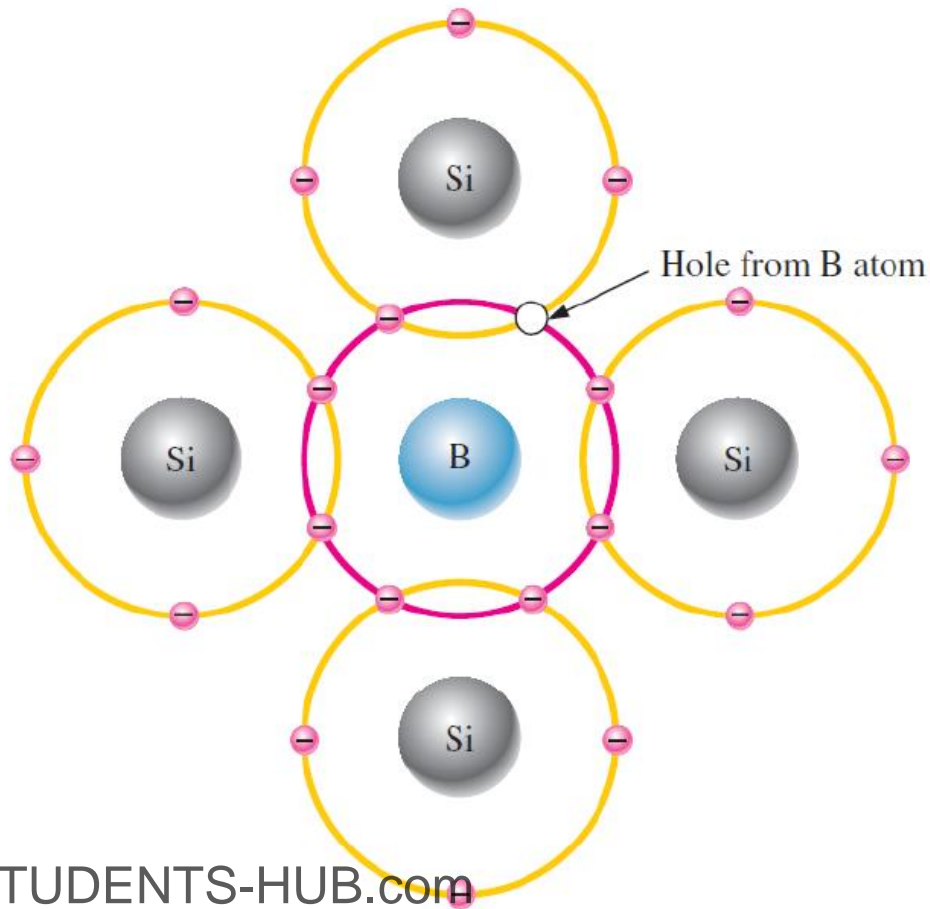
**Conduction in n-type material**

P - type semiconductor

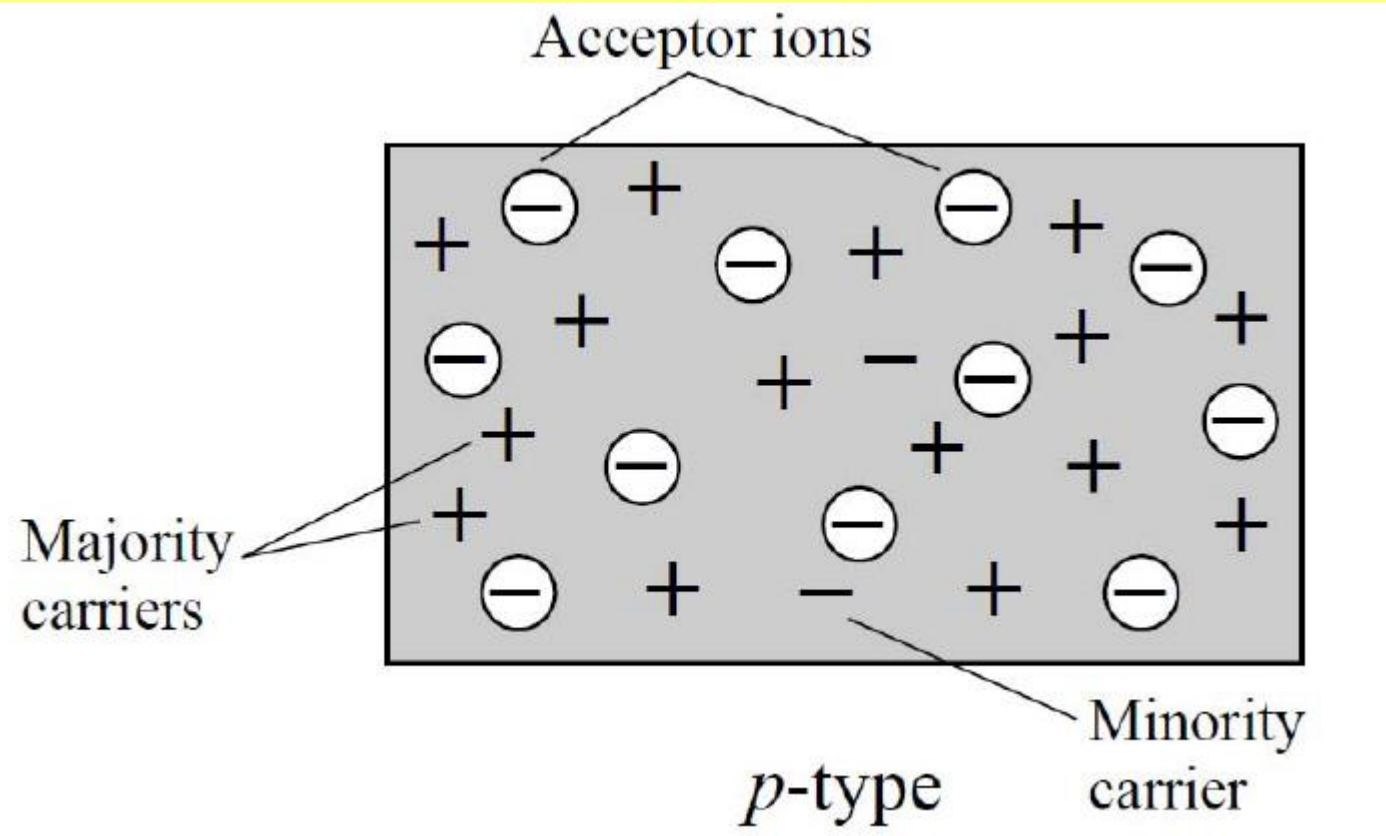
B (Boron) has three valence electrons (acceptor atom)

We add (  $10^{15} - 10^{17}$  ) B atoms/cm<sup>3</sup>

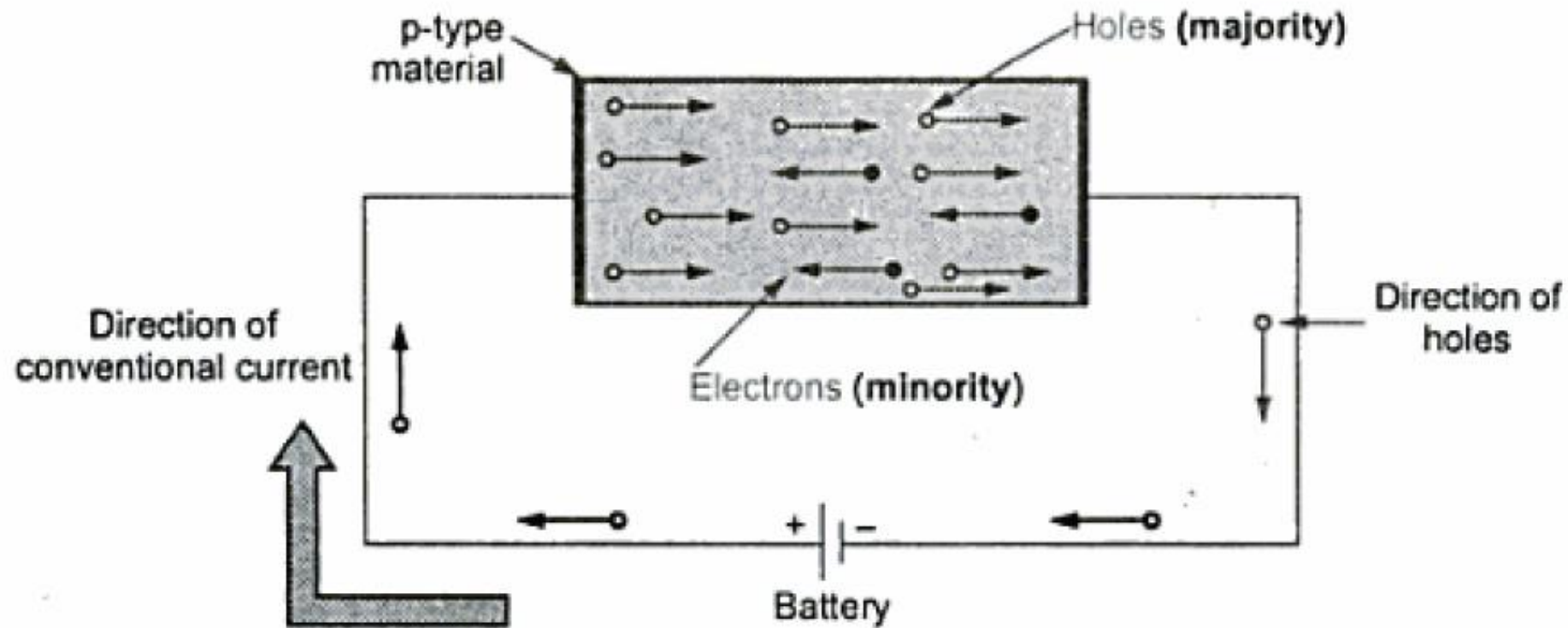
At room temperature there is  $5 \times 10^{22}$  atoms/cm<sup>3</sup> in pure Si .



In the **p**-type material the **holes** are the **majority** and the free **electrons** are the **minority**.



# Conduction in p-type material

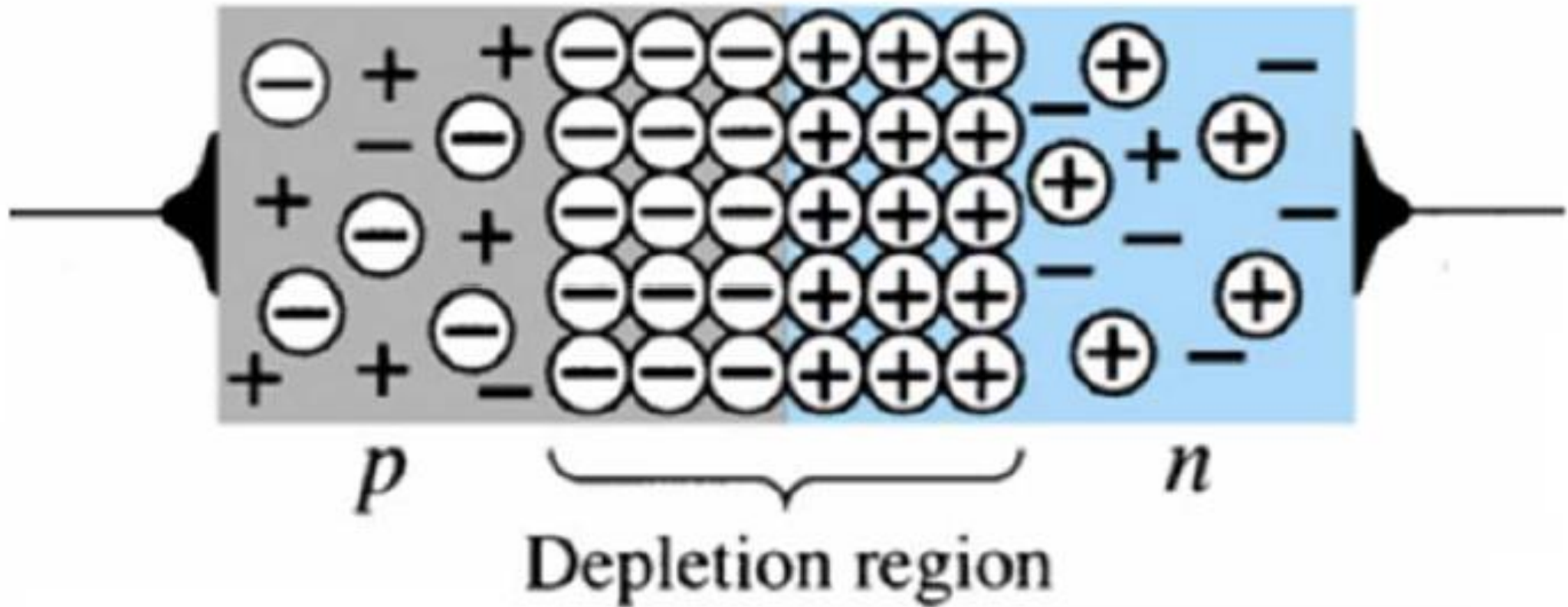


**Conduction in p-type material**



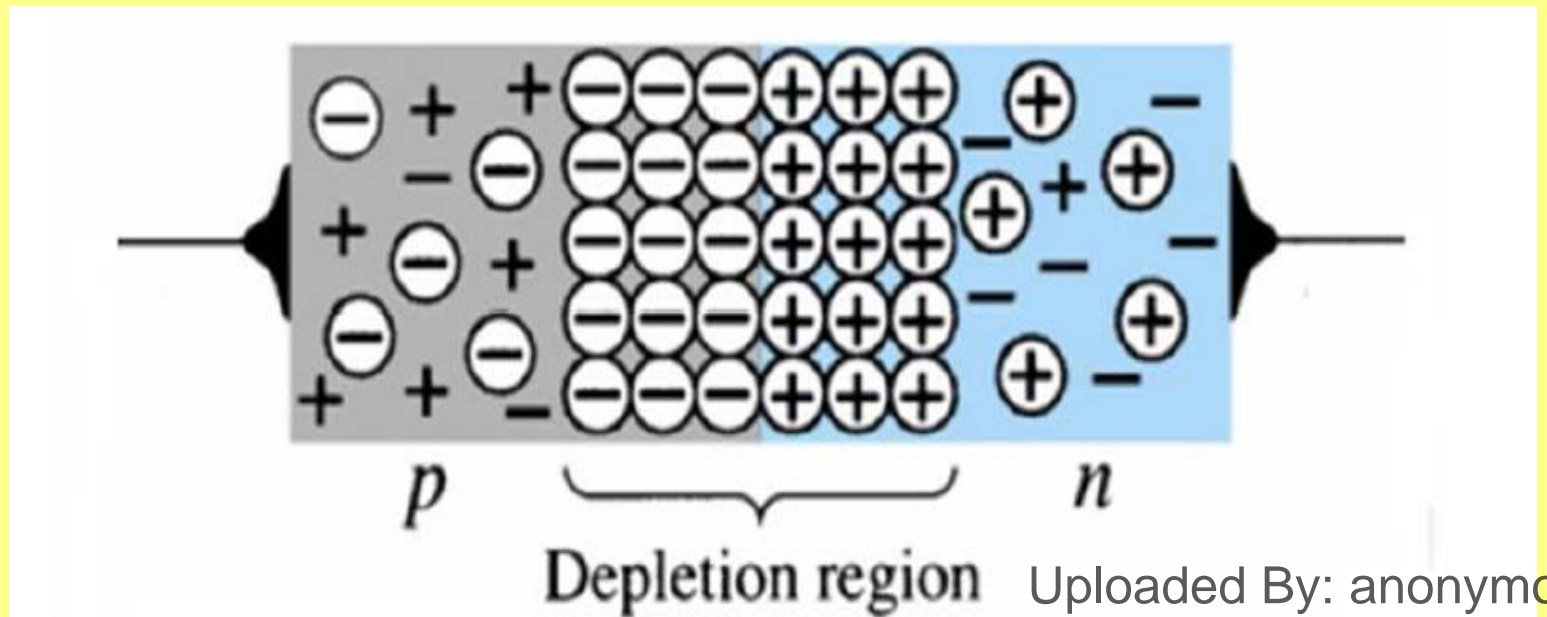
# Pn junction

- The p-n junction is the basis for diodes, certain transistors ,and other devices.

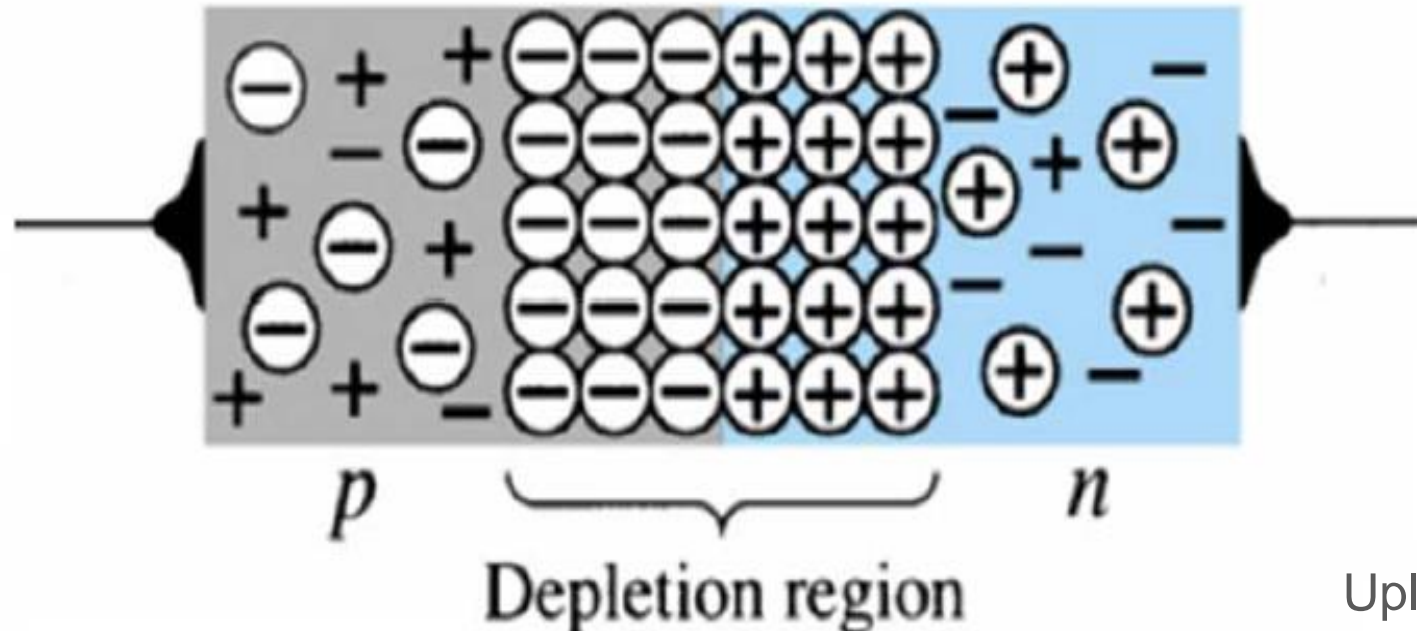




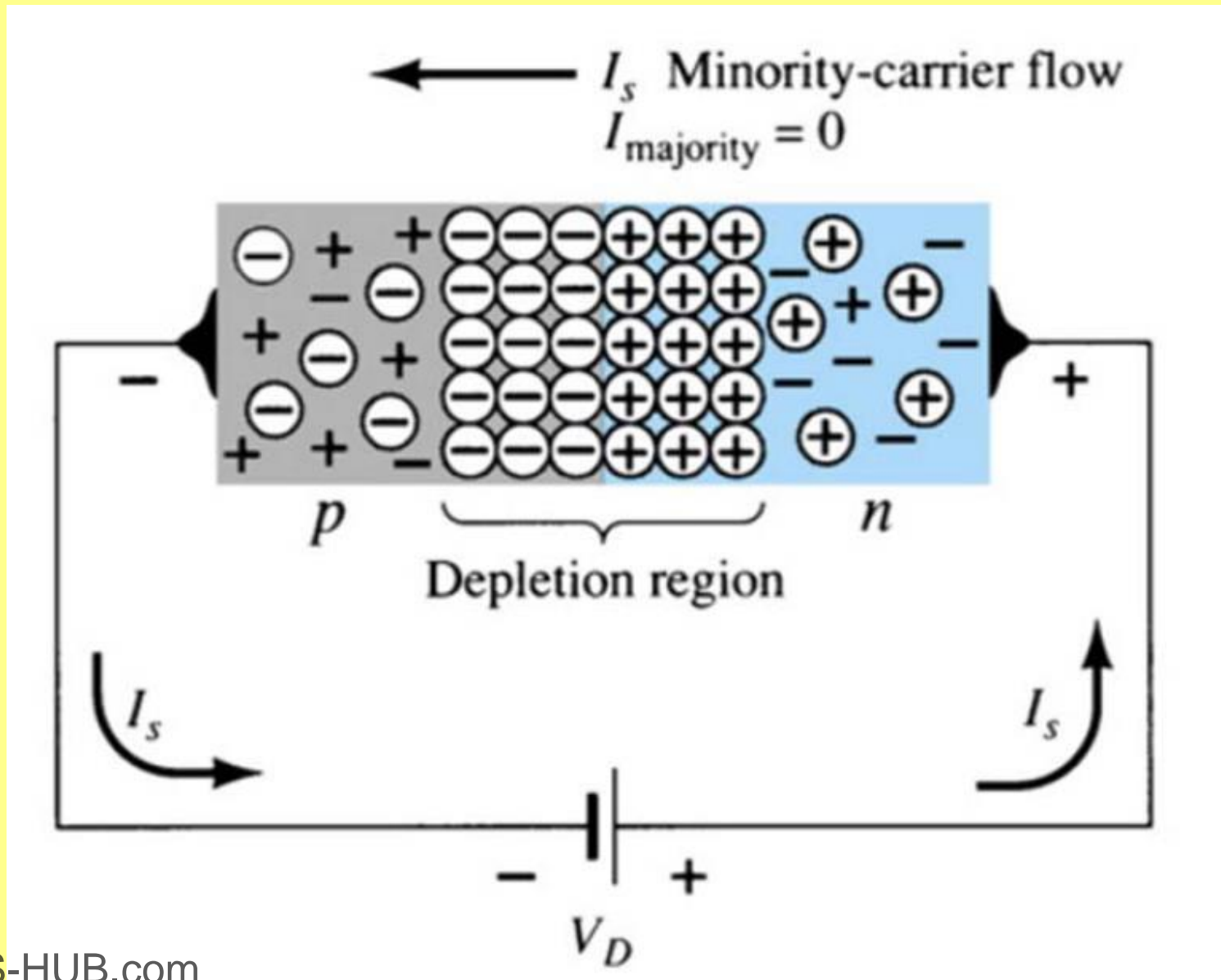
- 1) **Electrons** from the **n**-type material near the junction diffuse across the junction.
- 2) These **electrons** fill the **holes** in the **p**-type material adjacent to the junction.
- 3) As a result of **electrons** leaving the **n**-type material, donor ions are created on the n side of the junction.
- 4) When these **electrons** fill holes in the **p** side of the junction, acceptor ions are produced.
- 5) A wall of stationary **positive** ions is aligned with a wall of **negative** ions along the **n** and **p** sides of the junction.



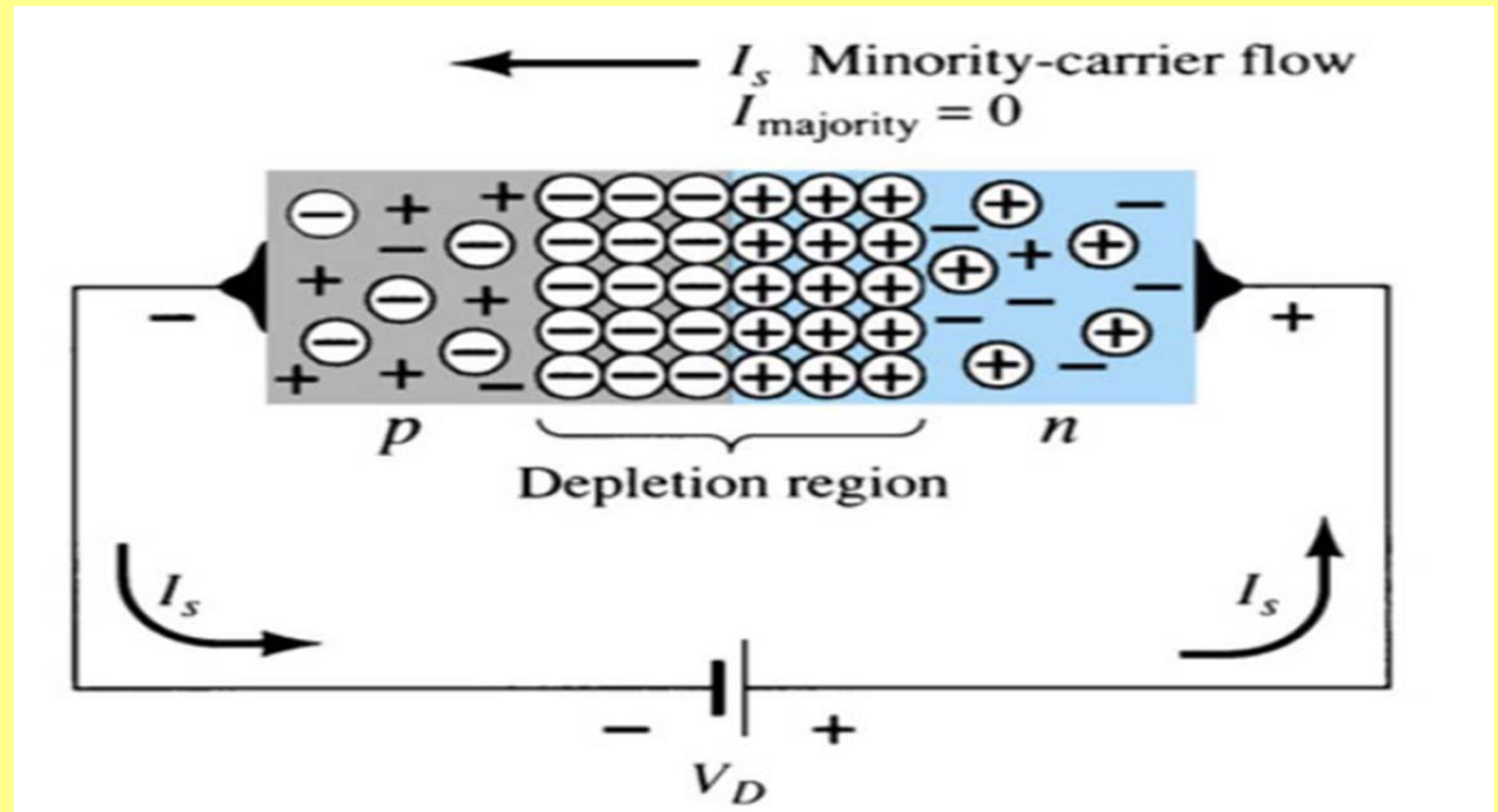
- 6 ) The space occupied between the ion walls is called **depletion region**.
- 7 )Whenever there exists a **positive** charge with respect to a **negative** charge , a voltage difference is set between charges ;(**Junction potential**, **Junction barrier**).
- 8 ) The **junction potential** acts as **potential barrier** that tend to prevent majority carriers from crossing the junction.
- 9 ) Minority carriers are aided by the **junction potential** .



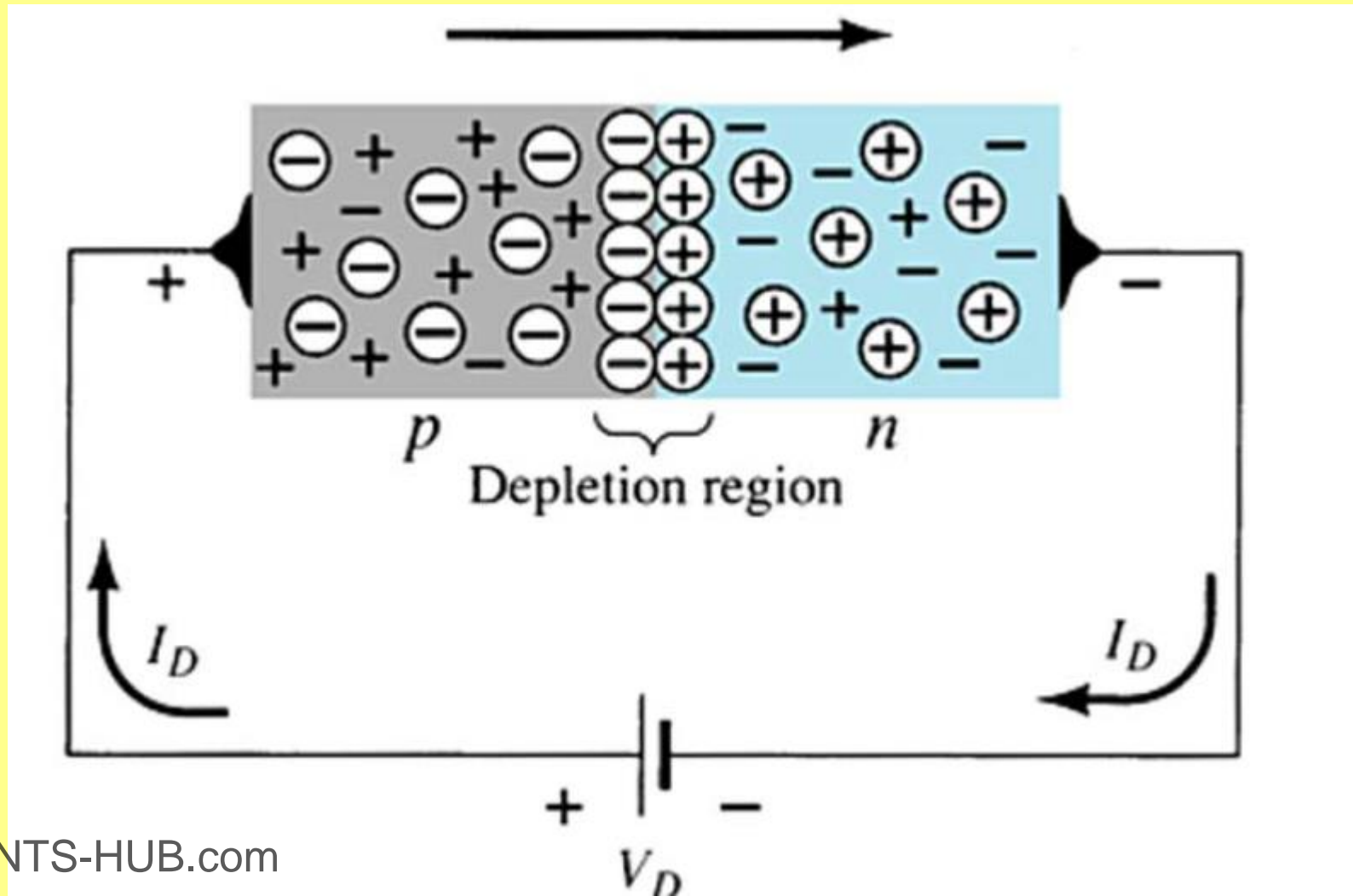
# Reverse bias of a pn junction



- ▶ The reverse voltage causes the **depletion region** to **widen**.
- ▶ The **electrons** in the **n**-type material are attracted toward the **positive** terminal of the voltage source.
- ▶ The **holes** in the **p**-type material are attracted toward the **negative** terminal of the voltage source.



# Forward bias of a pn junction



- ▶ The forward voltage causes the depletion region to narrow
- ▶ The electrons and holes are pushed toward the p-n junction
- ▶ The electrons and holes have sufficient energy to cross the p-n junction

